



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1708**
Shinichi IGARASHI et al. :

Appl. No. 10/566,158 : Art Unit 2881

Filed January 27, 2006 : Examiner Smyth, Andrew P.

TWO-DIMENSIONAL PATTERNING
METHOD, AND MANUFACTURING
METHOD OF ELECTRONIC DEVICE
AND MAGNETIC DEVICE USING THE
TWO-DIMENSIONAL PATTERNING
METHOD

AMENDMENT UNDER 37 C.F.R. 1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action having a mailing date of March 21, 2008, the period for response having been extended for one month by the attached petition, please amend the above-referenced U.S. patent application as follows: